

Ultrathin NiS Nanosheets as Advanced Electrode for High Energy Density Supercapacitors

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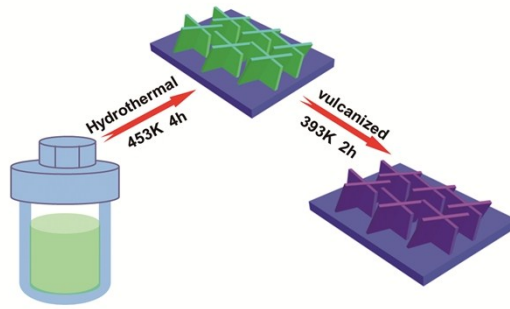


Fig. S1. Schematic illustration of the growth process of NiS nanosheets on Ni foam.

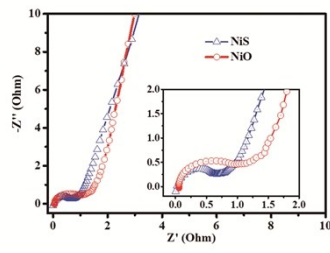


Fig. S2 The electrochemical impedance spectra (EIS) of the NiS and NiO nanosheets.

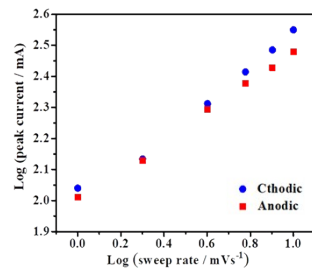


Fig. S3. Log (i) versus log (v) profile.

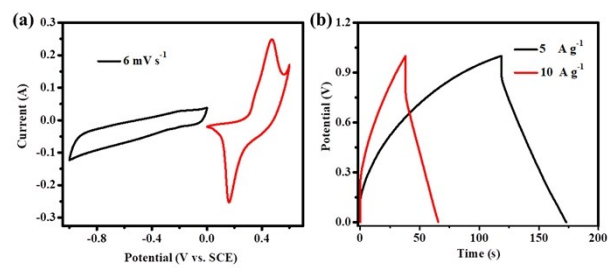


Fig. S4. CV and CD curves of AC electrodes.